## Electromagnetic Interference Shielding Material for Super-broadband: Ultrathin, Sandwich

## structure Multi-walled Carbon Nanotube/Silver Nanowire Film

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## **Supporting information**



Figure S1. Digital photos of the building blocks of (a) AgNWs, (b) MWCNTs, and (c) Ag/C-PM.
Digital photos of (d) AgNWs films and (e) Ag/C-7L. (f-h)Digital photograph of Ag/C-7L film with the state of twisting and buckling.



Fig. S2. Elemental mapping of (a-c) the Ag/C-3L film; Elemental mapping of (d-e) the Ag/C-5L



Figure S3. XRD spectra Ag NWs.



Figure S4. Cross-sectional SEM image of (a–b) the Ag/C-7L film.



Figure S5 (a) Conductivity of all samples. (b) Reflection coefficient (R)



Figure S6. The density of Ag NWs, MWCNTs, Ag/C-PM, Ag/3L, Ag/C-5L, and Ag/C-7L films.

Number	Samples	EMI SE (dB)	Thickness (μm)	EMI SE/t (dB/mm)	Ref.
1	MWCNT/cellulose/Ag NWs film	23.8	154	155	1
2	rGO/Ag NWs	24.0	100	240	2
3	graphene/ Ag NWs/graphene	38.0	10	3800	3
4	graphene/Ag NWs film	38.5	30	1283	4
5	MWCNTs/Ag NWs-PVDF	70.0	1174	60	5
6	CNTs/Polyurethane	43.5	2000	29	6

7	PVDF/CNTs/Ni@CNTs film	51.4	500	103	7
8	Al foil	66.0	8	8250	8
9	Cu foil	70.0	10	7000	8
10	MXene foam	32.0	6	5333	9
11	MXene/Nanocellulose film	24.0	47	511	10
12	MXene/RGO-epoxy solids	56.4	2000	28	11
13	MXene/CNT aerogel	62.8	1000	63	12
14	Graphene/PMMA foam	19.0	2400	8	13
15	Carbon/Graphene foam	24.0	24	1000	14
16	Graphene foam	25.0	300	83	15
17	MWCNT/WPU	24.0	50	480	16
18	SWCNT/epoxy	25.0	2000	13	17
19	Ag NW/PANI	48.0	13	308	18
20	Ag NW/epoxy	25.0	40	625	19
21	Ag NW/PVA	30.0	40	750	19
22	Ag NW/PS	32.0	800	40	20
23	Cu NW/PS	35.0	210	167	21
24	MWCNT/ Ag NWs/MWCNT film	72.0	12	60080	This works

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